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**PATENT NUMBER and  
ISSUE DATE**

**U.S. UTILITY Patent Application**

<b>APPL NUM</b> 10063128	<b>FILING DATE</b> 03/25/2002	<b>CLASS</b> 438	<b>SUBCLASS</b> 584	<b>GAU</b> 1783	<b>EXAMINER</b> A D M
<b>**APPLICANTS:</b> Liang Chao-Hu; Chen Chih-Hung; Tai Yu-Shan; Cheng Po-Lun;					
<b>**CONTINUING DATA VERIFIED:</b>					
<b>** FOREIGN APPLICATIONS VERIFIED:</b>					
<b>PG-PUB</b> <input type="checkbox"/> <b>DO NOT PUBLISH</b>			<b>RESCIND</b> <input type="checkbox"/>		
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials				<b>ATTORNEY DOCKET NO</b> NAUP0385USA	
<b>TITLE :</b> Method of forming a polysilicon layer					

U.S. DEPT. OF COMM./PAT. & TM.-PTO-4361 (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		<b>Assistant Examiner</b>	<b>Total Claims</b> <b>Print Claim for O.G.</b>
<b>ISSUE FEE</b>		<b>Primary Examiner</b>	<b>DRAWING</b>
<b>Amount Due</b>	<b>Date Paid</b>		<b>Sheets Drwg.</b> <b>Figs. Drwg.</b> <b>Print Fig.</b>
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		<b>PREPARED FOR ISSUE</b>	<b>Applicati n Examiner</b>
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